



PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re A	application of:)	
KAZU	HIKO FUKUTANI ET AL.	: Examiner: L.X. X) : Group Art Unit: 1	
Applic	eation No.: 10/653,978)	113
Filed:	September 4, 2003	;)	
For:	POROUS MATERIAL AND PRODUCTION PROCESS THEREOF	:) :) August 15, 2005	

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

SECOND INFORMATION DISCLOSURE STATEMENT

Sir:

In compliance with the duty of disclosure under 37 C.F.R. § 1.56 and in accordance with the practice under 37 C.F.R. §§ 1.97 and 1.98, the Examiner's attention is directed to the documents listed on the enclosed Form PTO-1449. Since the U.S. Patent and Trademark Office waived the requirement under 37 C.F.R. § 1.98 (a)(2)(i) for submitting a copy of each cited U.S. patent and each U.S. patent application publication for all U.S. national patent applications and for all international applications that have entered the national stage under 35 U.S.C. § 371, no copies of such documents are enclosed.

Copies of the other listed documents are, however, enclosed.

This Information Disclosure Statement is, in part, to make of record copending Application No. 10/656,242 and the documents cited therein, which documents have not yet been disclosed in the subject application. The Examiner's attention is also directed to Office Actions issued in that case, copies of which are enclosed.

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The concise explanation of relevance for the non-English documents may be found, inter alia, in the English language abstracts attached thereto and/or in the specification of co-pending Application No. 10/656,242 where they are cited. In addition, the concise explanation of relevance for JP 2001-273622 may be found in U.S. Patent Application Publication No. 2001/036563 A1, which is in the same patent family. Furthermore, the concise explanation of JP 9-157062 and JP 2001-261376 may be found in the attached English language translations, which were generated by a computer at the Japanese Patent Office web site. Lastly, Applicants note that WO 03/078685 A1 is a publication of an international application from which co-pending Application No. 10/656,242 claims priority under 35 U.S.C. § 120.

CONCLUSION

It is respectfully requested that the above information be considered by the Examiner and that a copy of the enclosed Form PTO-1449 be returned indicating that such information has been considered.

We also enclose a check for the required fee of \$180.00 to cover the Information Disclosure Statement under 37 C.F.R. § 1.97(c)(2).

Applicants' undersigned attorney may be reached in our New York office by telephone at (212) 218-2100. All correspondence should continue to be directed to our address given below.

Respectfully submitted,

Attorney for Applicants Registration No. 48,512

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FORM PTO 1449 (modified)			ATTY DOCKET NO. 03500.017112 APPLICATION NO. 10/653,978			78		
U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE P LIST OF REFERENCES CITED BY APPLICANT(S)			APPLICANT Kazuhiko Fukutani et al.					
(Use several sheets if ne essary) AUG 1 6 2005			FILING DATE September 4, 2003 GROUP 17		775			
	E.		U.S. PATENT DOCUMENTS					
*EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE		
	6,610,463 B1	08/26/03	Ohkura et al.	430	322	08/29/00		
	2004/0001964 A1	01/01/04	Ohkura et al.	428	596	08/29/00		
	2001/0036563 A1	11/01/01	Watanabe et al.	428	694T			
	2002/0031008 A1	03/14/02	Den et al.	365	173			
	2002/0086185 A1 07/04/0 2004/0048092 A1 03/11/0		Yasui et al.	428	694TS			
			Yasui et al.	428 642				
	6,602,620 B1	08/05/03	Kikitsu et al.	428	694T			
	2005/0053773 A1	03/10/05	Fukutani et al.	428	209	08/06/04		
FOREIGN PATENT DOCUMENTS								
	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION YES/NO/ OR ABSTRACT		
JF	2001-273622	10/05/01	Japan			Abstract		
JF	52-78403	07/01/77	Japan			No		
JF	62-270473	11/24/87	Japan			No		
JF	63-220411	09/13/88	Japan			No		
JF	7-73429	03/17/95	Japan			Abstract		
	OTHER	R DOCUMENT(S	(Including Author, Title, Date, Pertinent Pages, Etc.)					
	M. Jacobs et al., "Unbalanced Magnetron Sputtered Si-Al Coatings: Plasma Conditions and Film Properties Versus Sample Bias Voltage," 116-119 Surface and Coatings Technology 735-41 (1999).							
	C.D. Adams et al., "Phase Separation During Co-Deposition of Al-Ge Thin Films," 7(3) <u>J. Mater.</u> Res. 653-67 (March 1992).							
		C.D. Adams et al., "Transition from Lateral to Transverse Phase Separation During Film Codeposition," 59(20) Appl. Phys. Lett. 2535-37 (November 1991).						
	M. Atzmon et al., "Phase Separation During Film Growth," 42(2) <u>J. Appl. Phys.</u> 442-46 (July 1992).							
EXAMINER	1.002).		DATE CONSIDERED					

^{*}EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

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U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE LIST OF REFERENCES CITED BY APPLICANT(S)			APPLICANT Kazuhiko Fukutani et al.					
(Use several sheets if necessary)			FILING DATE September 4, 2003			GROUP 1775		
				U.S. PATENT D	OCUMENTS			
*EXAMINER INITIAL	DOCUMENT NUMBER DATE		DATE		NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
		6,027,796	02/22/00)	Kondoh et al.	428	312.8	
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		DOCUMENT NUMBER	DATE		COUNTRY	CLASS	SUBCLASS	TRANSLATION YES/NO/ OR ABSTRACT
	JP	9-157062	06/17/97	,	Japan			Translation
	JP	2001-261376	09/26/01	1	Japan			Translation
	wo	03/069677 A1	08/21/03		International			<u> </u>
	wo	03/078685 A1	09/25/03	,	International			Abstract
	JP	2001-101644	04/13/01		Japan			Abstract
<u> </u>	OTHER DOCUMENT(S) (Including Author, Title, Date, Pertinent Pages, Etc.)							
		C.D. Adams, et al. "Monte Carlo Simulation of Phase Separation During Thin-Film Codeposition," 74(3) J. Appl. Phys. 1707-15 (August 1993).						
EXAMINER				DATE	CONSIDERED			

Sheet 2 of 2

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